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**Details of Paper Published :**

<b>Sr. No</b>	<b>Paper Name</b>	<b>Publication Details</b>	<b>Date/Year of Paper Published</b>
1	“Synthesis Characterization and Electrochemical properties of SILAR deposited V <sub>2</sub> O <sub>5</sub> thin film”	IJRSET, 2(1) (2015) 47-51. (ISSN 2349-476X (ONLINE))	2014-15
2	“ Synthesis and characterization of vanadium oxide (V <sub>2</sub> O <sub>5</sub> ) thin film electrode for super capacitors: Effect of Annealing ”	IOSR Journal of Applied Physics (IOSR-JAP) 1(8)(2016) 7-13 (e-ISSN: 2278-4861)	2015-16
3	“ Enhancing Electrochemical Performance of V <sub>2</sub> O <sub>5</sub> Thin Film by using Ultrasonic Weltering”	IOSR Journal of Applied Physics (IOSR-JAP) 7(6)(2015) 41-45 (e-ISSN: 2278- 4861)	2015-16
4	“ Effect of Annealing on Super-capacitive Performance of Electrodeposited Vanadium-Nickel Oxide Thin Film Electrode ”	J. IJIR 5 (2) (2016) 595-599. (ISSN: 2454-1362)	2016-17
5	“Nanostructured Nickel Doped Vanadium Pentoxide Thin Films with Improved Surface Morphology and Electric Conductivity for Super capacitor Applications”	International Journal of Scientific & Engineering Research, 8, (2), 2017 759-763.	2016-17
6	“Super-capacitive Performance of Nickel Doped Vanadium Oxide Thin Film Electrodes: Effect of Surface Treatments”	International Journal of Engineering Technology, Management and Applied Sciences, 5, (7), July 2017 ISSN 2349-4476, 728-733.	2017-18
7	“Improvement in Electrochemical Performance of Spray Deposited V <sub>2</sub> O <sub>5</sub> ”	Materials Today: Proceedings 4 (2017), 3549-3556.	2017-18

	Thin Film Electrode by Anodization”		
<b>8</b>	“Structural and Electrochemical Behavior of Electro-deposited Ni Doped V <sub>2</sub> O <sub>5</sub> Thin Film on Quenched Stainless Steel Substrate”	Materials Today: Proceedings 4 (2017), 3557-3564.	2017-18
<b>9</b>	“ Performance and Evaluation of V <sub>2</sub> O <sub>5</sub> Thin Film Electrode for Electrochemical Supercapacitor: Effect of Electrolytes ”	International Journal of Engineering Research and Applications <b>IJERA</b> , 10 (9) Sept 2020 ISSN: 2248-9622, 60-64.	2020-21